Investigating Vanadium Dioxide Insulator-Metal Transition with Raman and Ultrafast Pulses

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VO₂ Metal-Insulator Transition





Change in optical properties

Pashkin, C. Kübler, H. Ehrke, R. Lopez, a. Halabica, R.F. Haglund, R. Huber, and a. Leitenstorfer, Physical Review B **83**, 195120 (2011).

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Our Work

- Studying optically induced phase transition with pump-probe configuration
 - Varying fluence
 - Varying film temperature
- Raman Spectroscopy of films grown on different films

Pump-probe set up



Measure Drop in reflectivity



Varying Power of Pump Beam



Why mount sample in cryostat?

Effects of Temperature vs. Strong electric fields freeing electrons

 \rightarrow Some controversy as to the main cause: fast response suggests electronic response vs. change in crystal lattice

T. Cocker, L. Titova, S. Fourmaux, G. Holloway, H.–C. Bandulet, D. Brassard, J.–C. Kieffer, M. El Khakani, and F. Hegmann, Physical Review B 85, 155120 (2012).

D. Hilton, R. Prasankumar, S. Fourmaux, a. Cavalleri, D. Brassard, M. El Khakani, J. Kieffer, a. Taylor, and R. Averitt, Physical Review Letters **99**, 226401 (2007).

Cooling film in cryostat



Raman Spectroscopy Studies

- Used Commercial Raman Spectrometer
 - Difficult to see peaks of VO₂ thin films: Maximizing our signal
- Differences between films due to differences in microstructure

Incident Beam Wavelength: minimizing effect from substrate



VO₂ film on Quartz



VO₂ film on Sapphire

Raman Spectra through MIT





Raman Peak amplitude and cw Optical Reflection Measurements

Summery

- See an ultrafast response in films, even at lower temperatures
- Able to identify VO₂ Raman peaks
 - Can see phase transition in spectra
 - Transition temperature effected by microstructure
- Future work: Further analysis on the relaxation of MIT

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Comparison of Substrates In Ultrafast Transition



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VO₂ on Sapphire Grain Size ~20nm



XRD Characterization

35

35.5

36

36.5

37

20 (deg)

37.5

38

38.5

39

Polarization of incident/reflected beam



Multiple peak fits: VO₂ on SiO₂

